

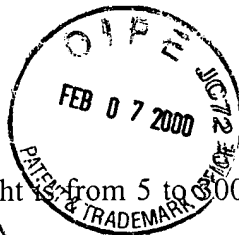
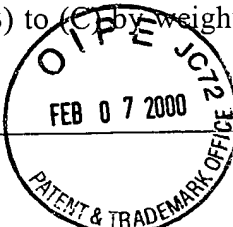
AMENDMENT UNDER 37 C.F.R. §1.111  
U.S. Appl. No. 09/295,329

(C) a nitrogen-containing basic compound;

(D) [a fluorine and/or] at least one of a fluorine-containing surfactant and a silicon-containing surfactant, and

(E) a solvent;

wherein the ratio of (B) to (C) by weight is from 5 to 1000 and the ratio of (A) to (D) by weight is from 500 to 20,000.



Claim 7, line 7, delete "3-ethoxypropionate" and replace with -- 3-ethoxypropionate --.

9 (amended). A positive photosensitive resin composition comprising:

(A) a polymer which has alicyclic hydrocarbon skeletons and decomposes under the action of an acid to become alkali-soluble,

(B) a compound which generates an acid upon irradiation with actinic rays,

(C) a nitrogen-containing basic compound,

(D) [a fluorine and/or] at least one of a fluorine-containing surfactant and a silicon-containing surfactant, and

(E) a solvent comprising as a first solvent at least one solvent selected from the following group (a) in an amount of 60 to 90 % by weight based on the total solvent and as a second solvent a solvent selected from the following group (b) in an amount of 10 to 40 % by weight to the total solvent; the group (a) consisting of ethyl lactate, propylene glycol monomethyl ether acetate, propylene glycol monomethyl ether propionate, methyl 3-methoxypropionate and ethyl 3-ethoxypropionate, and the group (b) consisting of solvents having a viscosity of not higher than 1 centipoise at 20°C.

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